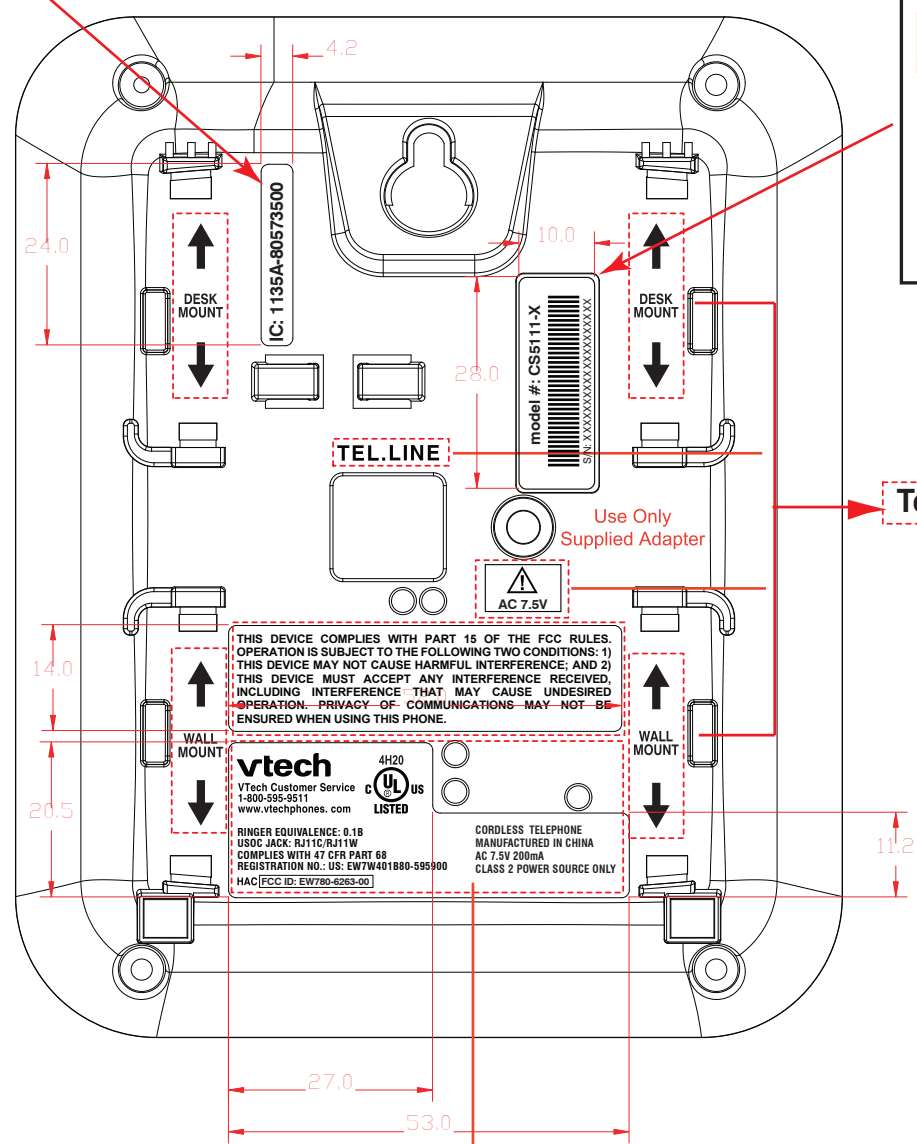


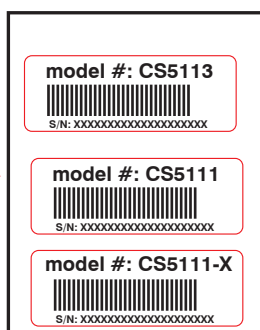
CS51XX ENGRAVING ARTWORK FOR ES V2.0+New BAKEN RF

IC label

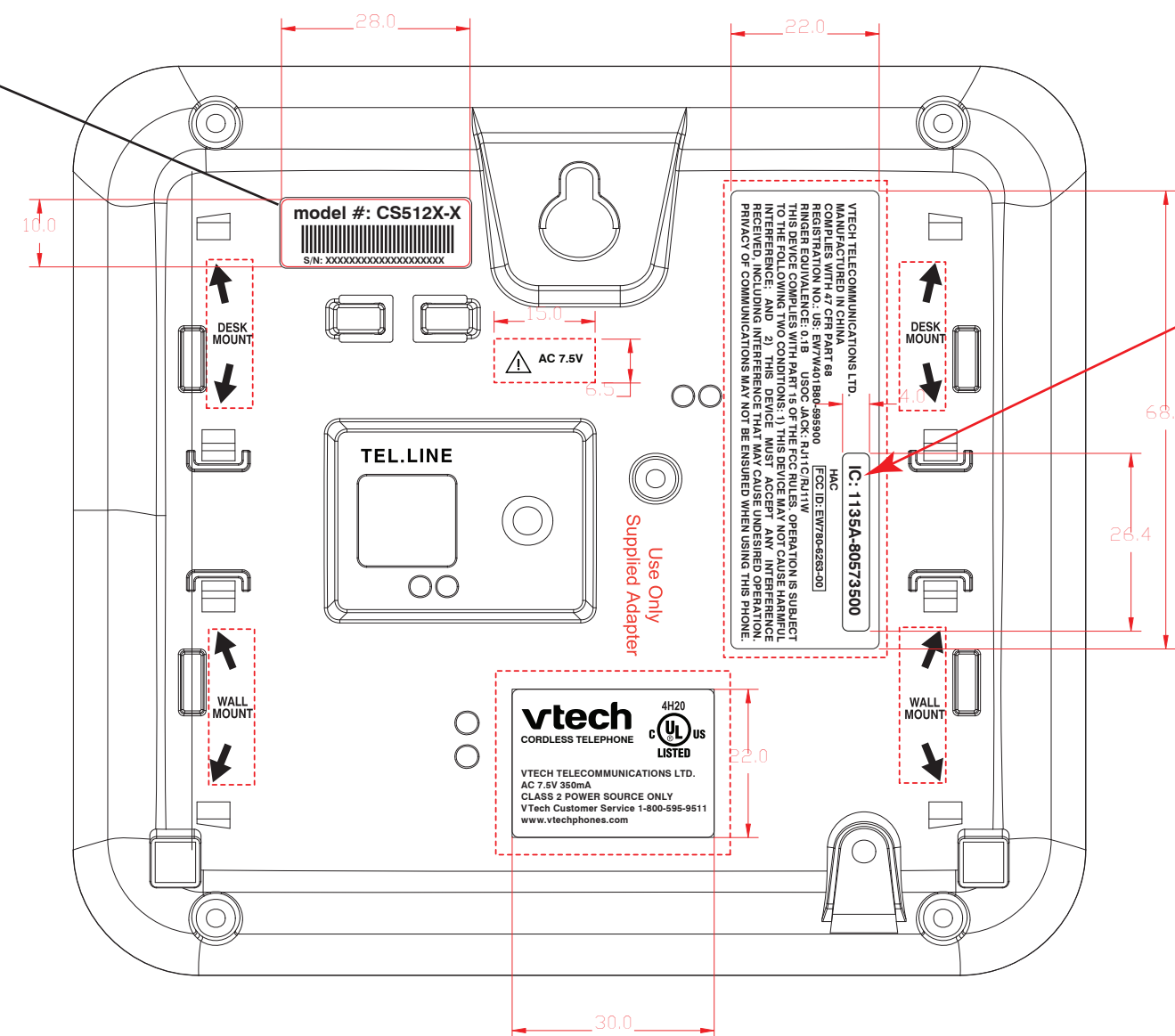
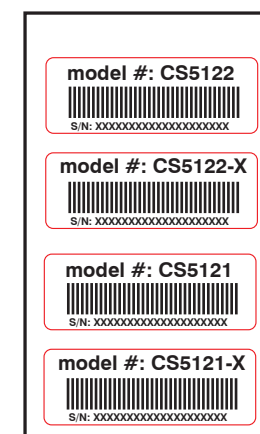


Text engraved in recess 0.3 mm depth
Text surface in high gloss

c-BS BTM
(For CS5111/CS5111-X /CS5113)



Text engraved in 0.3mm raised



Text engraved in recess 0.3 mm depth
Text surface in high gloss

Text engraved in 0.3mm raised

CI-BS BTM
(For CS5121/CS5121-X/ CS5122)Rev.0

IC label